

### Problem session 3

#### Problem 3.1

Consider a linear ionic crystal containing  $2N$  ions of alternating charge  $\pm q$ . Assume two different repulsive potentials: (a)  $A/R$  and (b)  $A/R^2$ . What would be the equilibrium separation between atoms ( $R_0$ ) and total energies for crystals (a) and (b)? What would be the total energy associated with crystal (b) if it is compressed so that the separation between atoms  $R = R_0/2$ ?

#### Problem 3.2

The cubic crystal is subjected to tension in  $[100]$  direction. Find the expressions in terms of elastic stiffnesses for Young's modulus and Poisson ratio as defined in Fig.21 in p.87 in Kittel's book.

#### Problem 3.3

Show that the minimum free energy in a crystal having  $N$  sites is reached only when a certain number of defects ( $n$ ) are available. Derive an expression for the concentration of vacant sites ( $C_V$ ) in a crystal kept at temperature  $T$  and compressive isotropic pressure  $P$ . Explain the quantities of activation energy and activation volume. Hint: Minimize the free energy  $G = U - TS + PV$ , expressed as a function of the number of vacant sites. The relation  $\ln X! \approx X(\ln X - 1)$ , valid for large  $X$ , might be useful.

#### B. Problem 3.4

Suppose that the energy required to remove a silicon atom from the bulk of a silicon crystal to the surface is  $4\text{eV}$ . Calculate the concentrations of Schottky vacancies in Si at normal conditions at  $300$  and  $1687\text{K}$ . Assume that the activation volume of a silicon vacancy is roughly equal to the Si atomic volume in the crystal. How much of isotropic pressure, in terms of magnitude and sign, should be applied at  $300\text{K}$  to lift the vacancy concentration up to that  $1687\text{K}$ ? Note, that  $1687\text{K}$  is a melting temperature for Si at normal conditions.